

Abstract

Monocrystalline silicon semiconductor wafer and method for producing same

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A method for producing a semiconductor wafer of monocrystalline silicon,
comprising in this order

the growing of a single crystal of silicon by the CZ method;

10 the dividing of at least one semiconductor wafer of monocrystalline silicon from the
single crystal;

a first, second, and third RTA treatment of the semiconductor wafer.

15 Drawing for the Abstract: Fig.6